



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

July 25, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

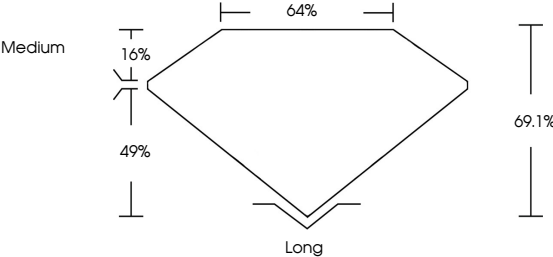
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG821632990

Report verification at igi.org

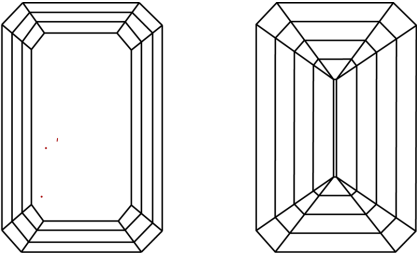
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

10.43 X 7.45 X 5.15 MM

4.01 CARATS

D

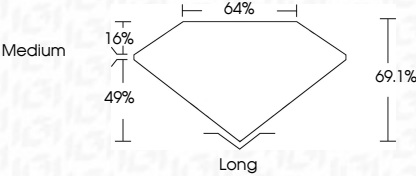
VVS 2

EXCELLENT

EXCELLENT

NONE

IGI LG821632990





IGI

July 25, 2026

IGI Report No LG821632990

EMERALD CUT

10.43 X 7.45 X 5.15 MM

Carat Weight

Color Grade

Clarity Grade

Depth

Table

Graile

4.01 CARATS

D

VVS 2

69.1%

64%

Medium

Long

EXCELLENT

EXCELLENT

NONE

IGI LG821632990

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

www.igi.org



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